

Dual Degree with Fashion Institute of Fashion Technology (FIT), New York

In a landmark achievement and first of its kind, NIFT has entered into an agreement for Dual Degree with FIT. Henceforth the selected students from NIFT would now be recipient of a Dual Degree from two premier fashion education institutes. As per the arrangement, the bachelor student shall study two years at NIFT followed by one year at FIT and graduating year at NIFT for award of dual degrees. FIT, New York has a history of 67 years in existence stands as a testimony to the credentials of the School. Further, NIFT was set up in the year 1986 with the FIT's active collaboration with UNDP assistance.